

CHIMICA DELLE SUPERFICI ED INTERFASI

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UNIVERSITÀ DEGLI STUDI DELL'AQUILA
LAUREA MAGISTRALE IN INGEGNERIA CHIMICA
A.A. 2013-2014

OUTLINE

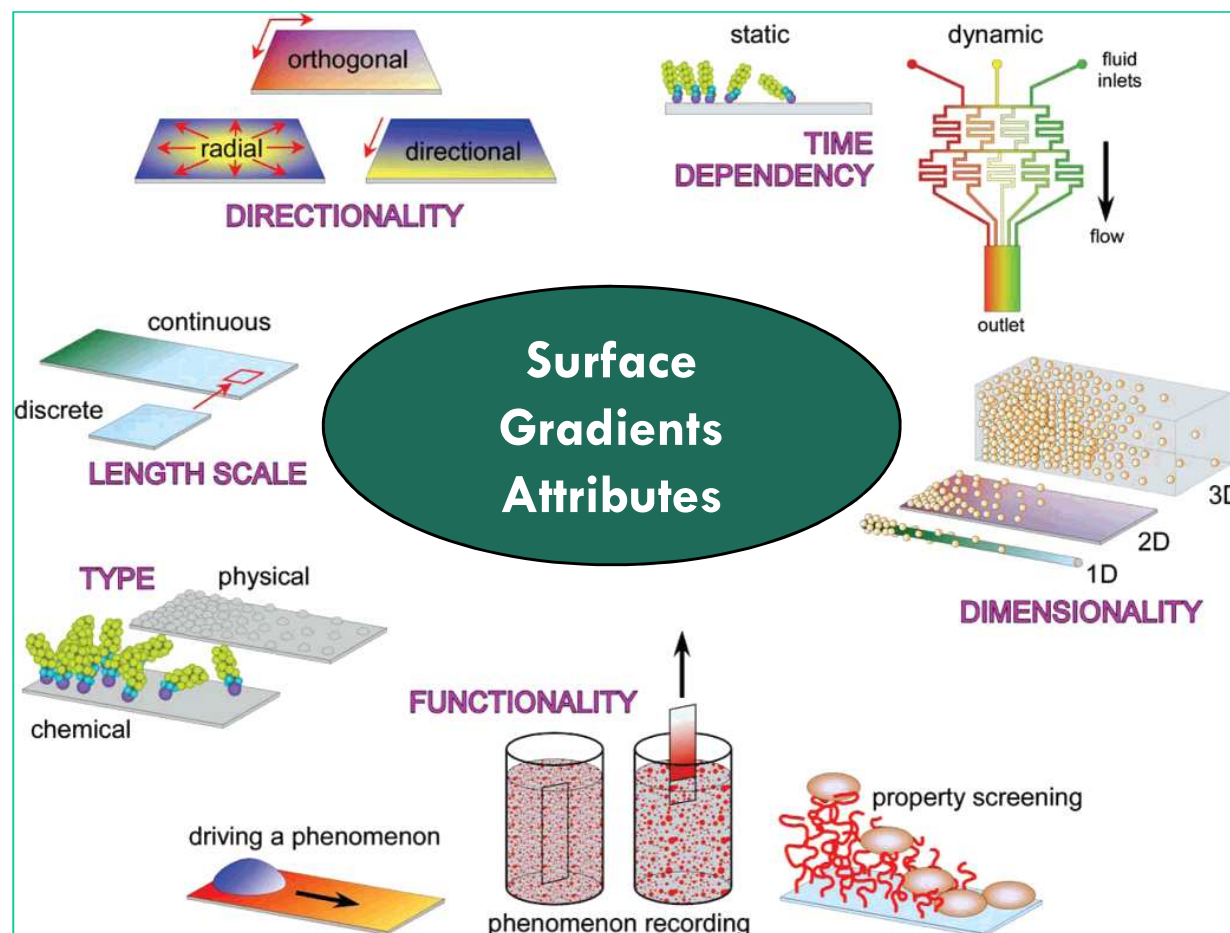
- SURFACE CHEMICAL GRADIENTS
- DROPLET MOVEMENT ON WETTABILITY GRADIENT
- WETTABILITY GRADIENT FORMATION
 - SILANES GRADIENT ON SI
 - THIOLS GRADIENT ON AU BY WITHDRAWING EC DESORPTION

SURFACE GRADIENTS PROPERTIES

THE SURFACE PHYSICAL AND CHEMICAL PROPERTIES CHANGE CONTINUOUSLY ALONG THE MATERIALS.

- PHYSICOCHEMICAL NATURE
- DIMENSIONALITY (1D, 2D, 3D)
- DIRECTIONALITY (UNIDIRECTIONAL, ORTHOGONAL OR RADIAL)
- LENGTH SCALE (CONTINUOUS OR DISCONTINUOUS)
- TEMPORAL DEPENDENCY (STATIC OR DYNAMICAL)
- FUNCTIONALITY

SURFACE GRADIENTS



SURFACE-CHEMICAL GRADIENT APPLICATIONS

SMART RESPONSIVE MATERIALS

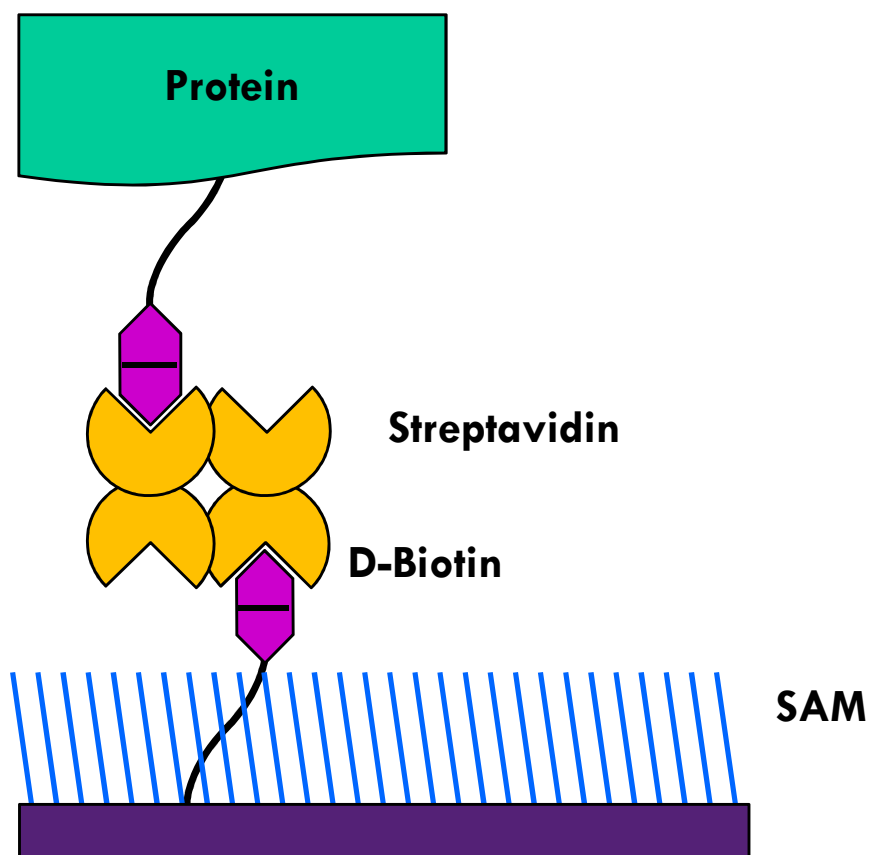
- DRIVING
- RECORDING
- SCREENING

(PHYSICOCHEMICAL PHENOMENA)

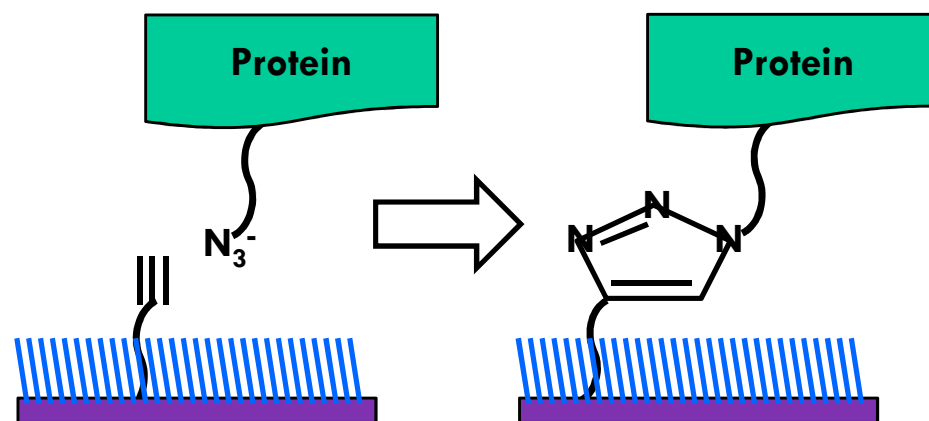
BIOLOGICAL APPLICATIONS

- CELL ADHESION
- PROTEIN ADSORPTION
- CELL GROWTH

SURFACES BIOFUNCTIONALIZATION



«Click Chemistry»

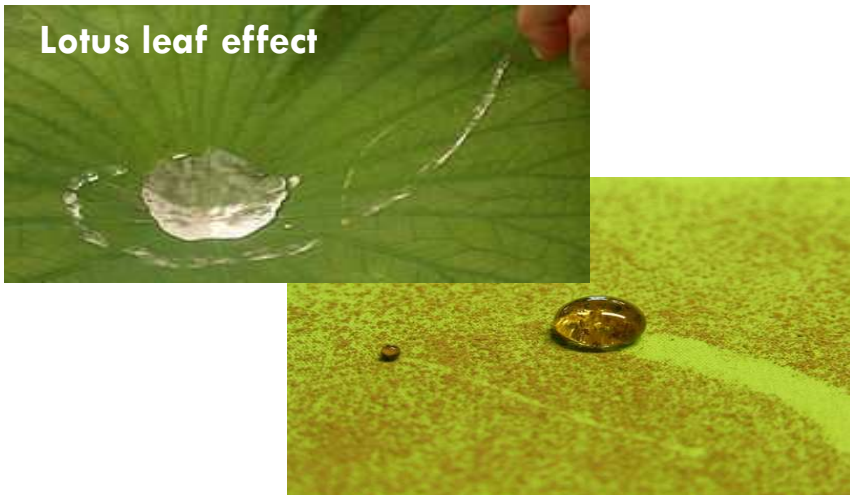


WETTABILITY GRADIENT

CHEMICAL HETEROGENEITY AND SURFACE ROUGHNESS

(MICRO/ NANO SCALE)

Lotus leaf effect

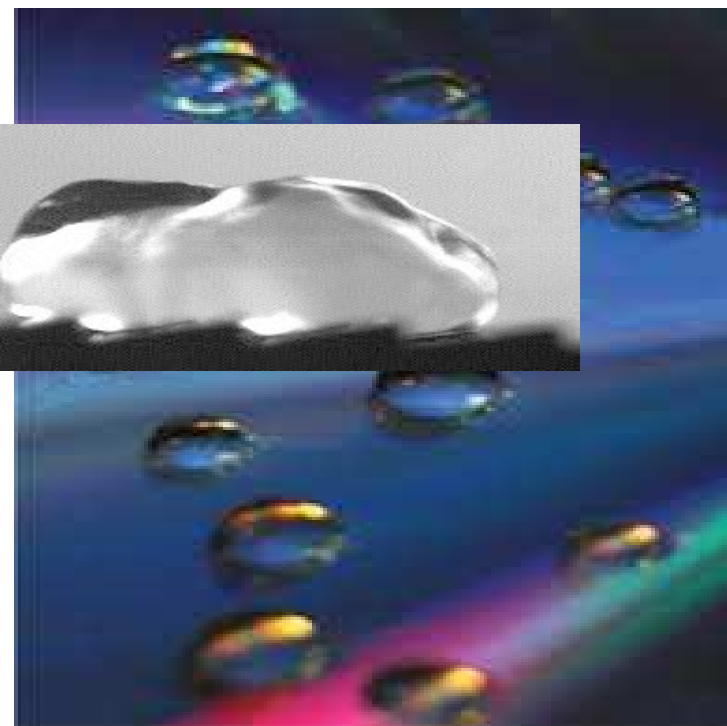
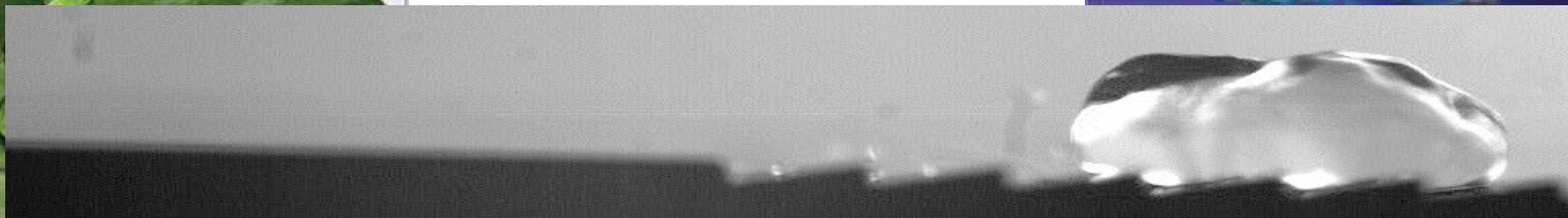


Superhydrophobic surfaces

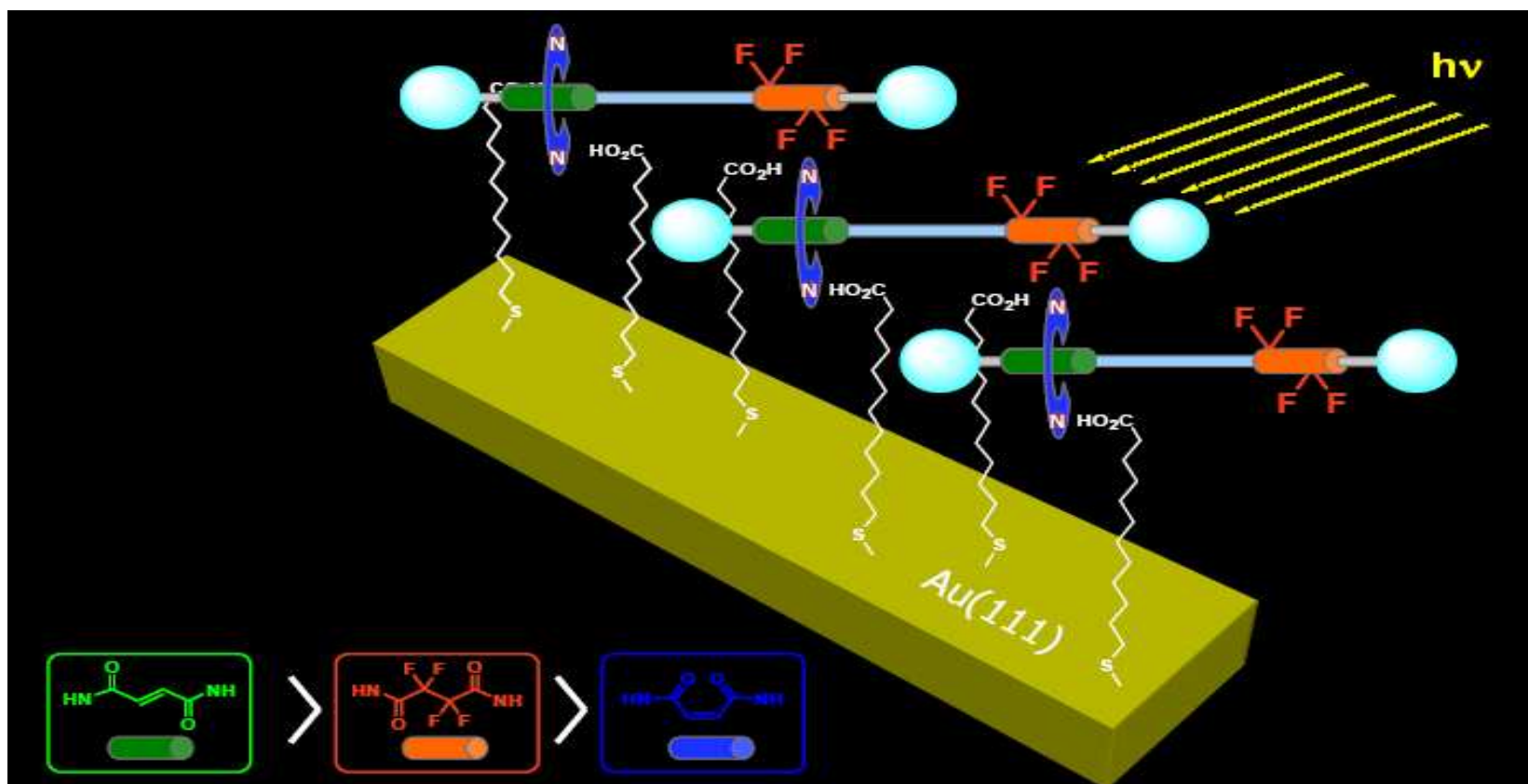


MAIN GOAL: DROPLETS MOVEMENT

... DUE TO WETTABILITY GRADIENT!!!



BENZYLIC AMIDE ROTAXANES

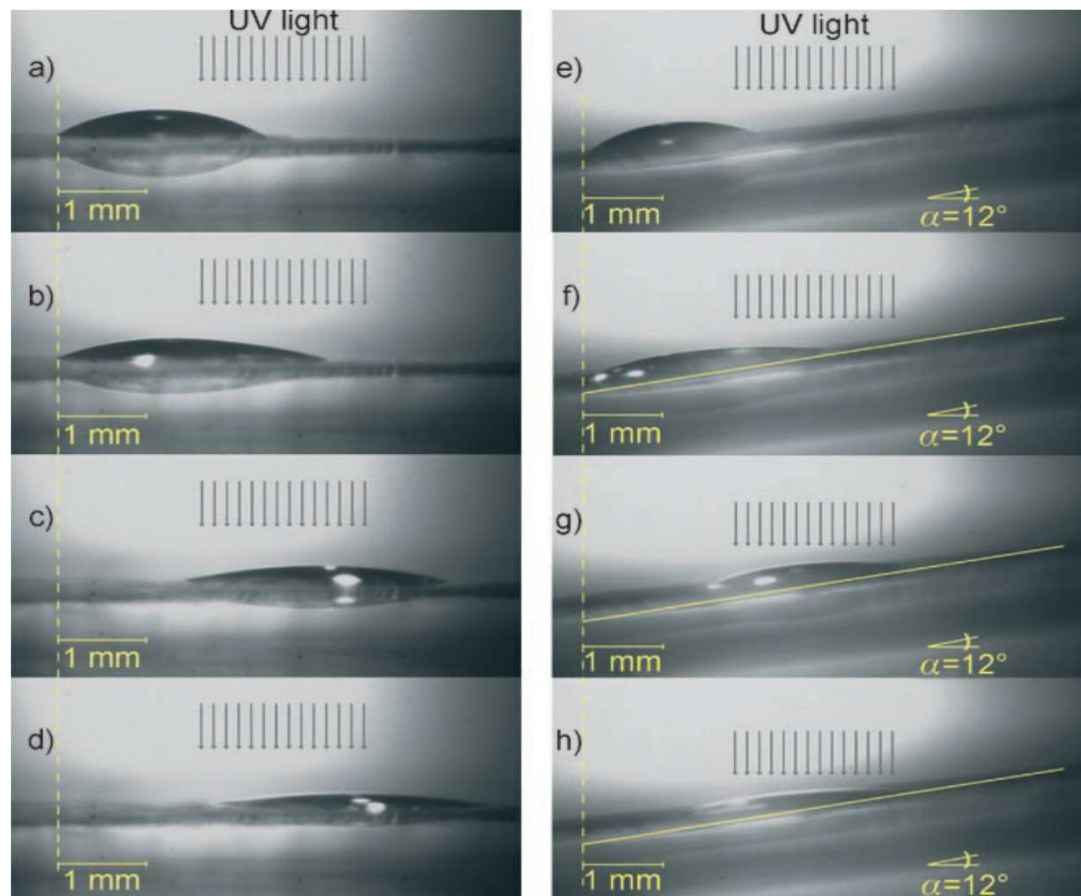


TRANSPORT ON SURFACE

UV-LIGHT ISOMERIZES THE FUMARAMIDE STATION, CAUSING THE DISPLACEMENT OF THE MACROCYCLE, WHICH CONCEAL THE FLUOROALKANE UNITS LEAVING A MORE POLAROPHILIC SURFACE

Nature Mat., 2005, 4, 704

Corso di Chimica delle Superfici ed Interfasi - G. Fioravanti



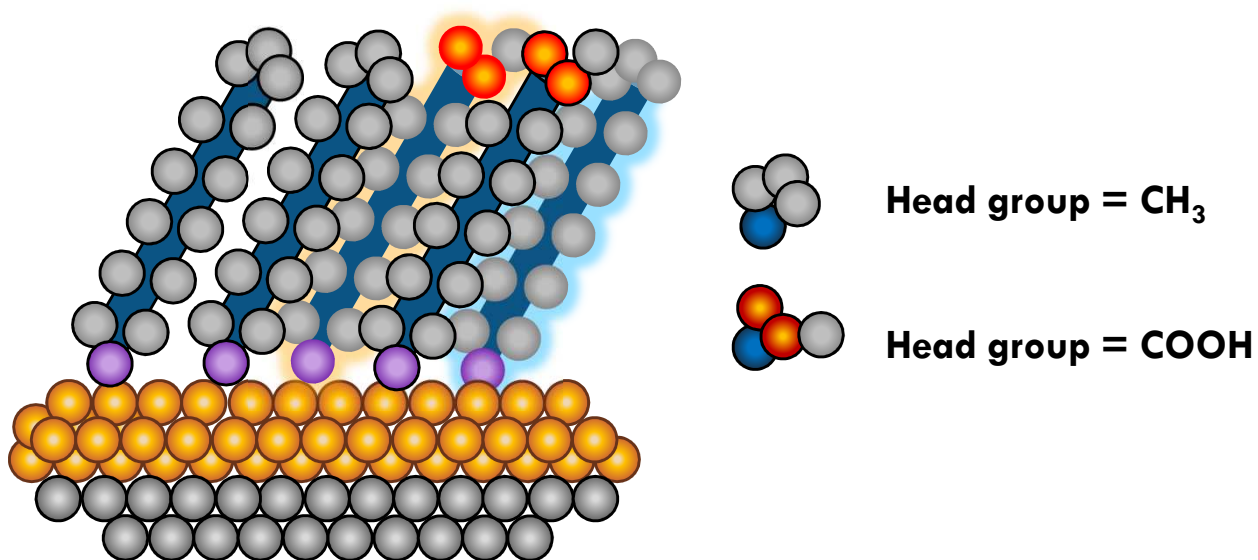
SURFACE-CHEMICAL GRADIENT PREPARATION TECHNIQUES

Technique		Adsorbate	Substrate
Diffusion	Vapour phase	Silanes	Si, PDMS
	Solvent	Silanes	Si
	Through a matrix	Alkanethiols, Silanes	Au
Printing	Contact	Alkanethiols, Silanes	Au, Si (also functionalized)
	Ink jet	Alkanethiols, Silanes	Au, Si
Advancing solution	Concentration gradient	Monomers, Proteins	Au, Si (also functionalized)
	Controlling reaction time	Alkanethiols, Silanes	Au, Si
	Depletion	Proteins	PDMS, Glass
Irradiation	Intensity, exposure time, mask	Silanes, Alkanethiols, Monomers, Proteins	Au, Si (also functionalized)
Controlled polymerization	Temperature, plasma or electropolymerization	Alkanethiols, Monomers	Au
Desorption	By potential or irradiation	Alkanethiols	Au

WETTABILITY GRADIENT BY MIXED SAM APPROACH

WHAT MEANS "MIXED SAM"?

TWO DIFFERENT FUNCTIONALITY (HYDROPHOBIC, HYDROPHILIC) WITH DIFFERENT DENSITIES ALONG THE SURFACE.



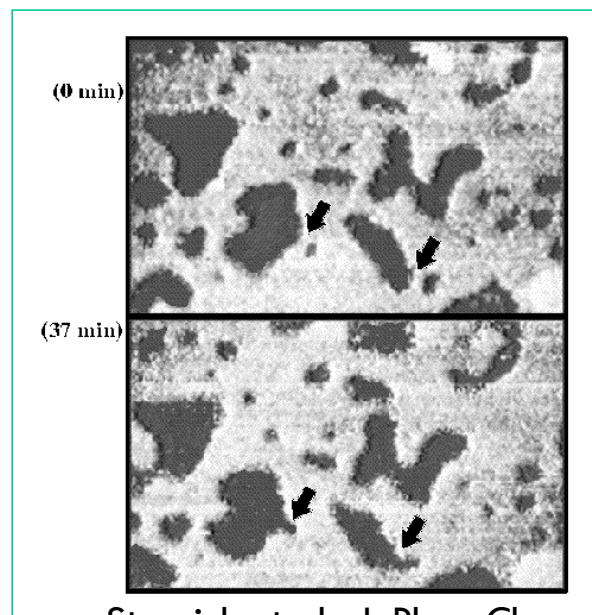
MIXED SAM FORMATION

1. **KINETIC CONTROL:** THE MOLECULES IN SOLUTION REACH RANDOMLY THE METAL SURFACE AND BIND IRREVERSIBLY TO IT. THE RESULT OF THIS PROCESS LEADS TO THE FORMATION OF AN ORGANIC MATRIX IN WHICH THE TWO COMPONENTS ARE ARRANGED RANDOMLY, IN SUCH PROPORTION AS TO REFLECT THE COMPOSITION OF THE STARTING SOLUTION.
2. **DIFFUSION MECHANISM:** THE IRREVERSIBLE CHEMISORPTION IS FOLLOWED BY A DIFFUSION AT THE SURFACE WHICH RESULTS IN A REDISTRIBUTION OF THE ADSORBATES, TO GIVE A FINAL SITUATION IN WHICH THEY ARE ARRANGED IN THE WAY THAT BEST SUITS THEM (ALBEIT LIMITED BY THE CONSTRAINTS IMPOSED BY THE KINETIC PHASE INITIAL ADSORPTION).

MIXED SAM FORMATION

3. **EXCHANGE MECHANISM:** ADSORPTION IS NOT AN IRREVERSIBLE PROCESS, BUT A DYNAMIC ONE: AFTER A FIRST STATISTICS ARRANGEMENT, THE CONTINUOUS PROCESSES OF ADSORPTION AND DESORPTION REQUIRE ACHIEVEMENT OF A FINAL THERMODYNAMIC EQUILIBRIUM, GENERALLY REPRESENTED BY THE FORMATION OF DOMAINS OF MOLECULES OF THE SAME KIND.

Two sequential STM images taken 37 min apart showing a SAM containing islands of $\text{CH}_3(\text{CH}_2)_{15}\text{S}$ - (topographically lower, shown as darker) surrounded by $\text{CH}_3\text{OCO}(\text{CH}_2)_{15}\text{S}$ - (topographically higher, shown as brighter) areas. The SAM was formed from a solution of 75% $\text{CH}_3\text{OCO}(\text{CH}_2)_{15}\text{SH}$ /25% $\text{CH}_3(\text{CH}_2)_{15}\text{SH}$ on $\text{Au}\{111\}$. Domain coalescence is observed at this time scale (indicated by the two arrows). The reverse process (one large domain separating into two smaller ones) was not observed.

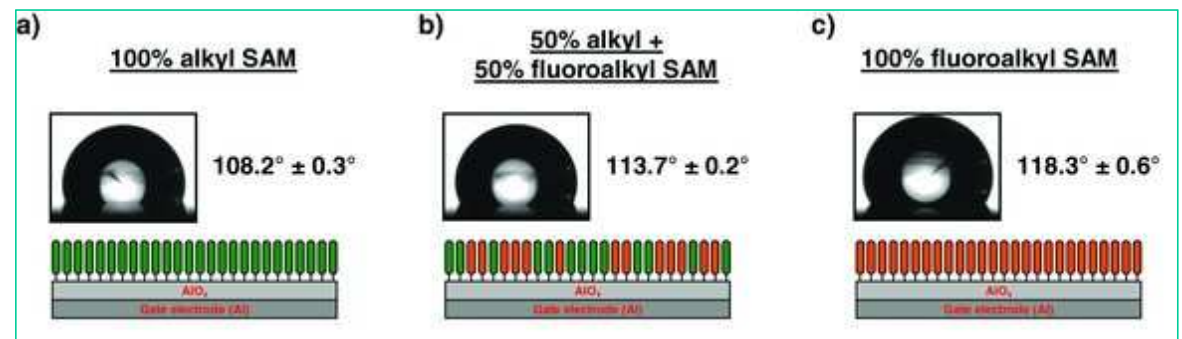
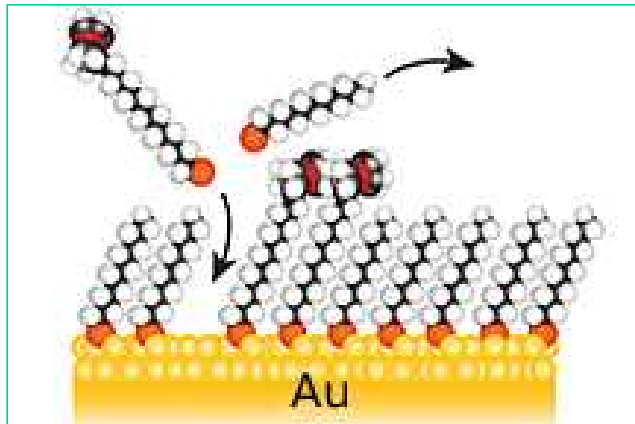


Stranick et al., J. Phys. Chem. 1994,98,76367646

MIXED SAM FORMATION

SIMULTANEOUS DEPOSITION VERSUS CONTROLLED DEPOSITION.

TYPICALLY, SOLUTION PROCESSING AND THE SAME ANCHOR CHEMISTRY ENABLE FULL CONTROL OF THE SAM COMPOSITION, WHICH DIRECTLY RELATES TO THE STOICHIOMETRIC COMPOSITION OF THE SOLUTION.



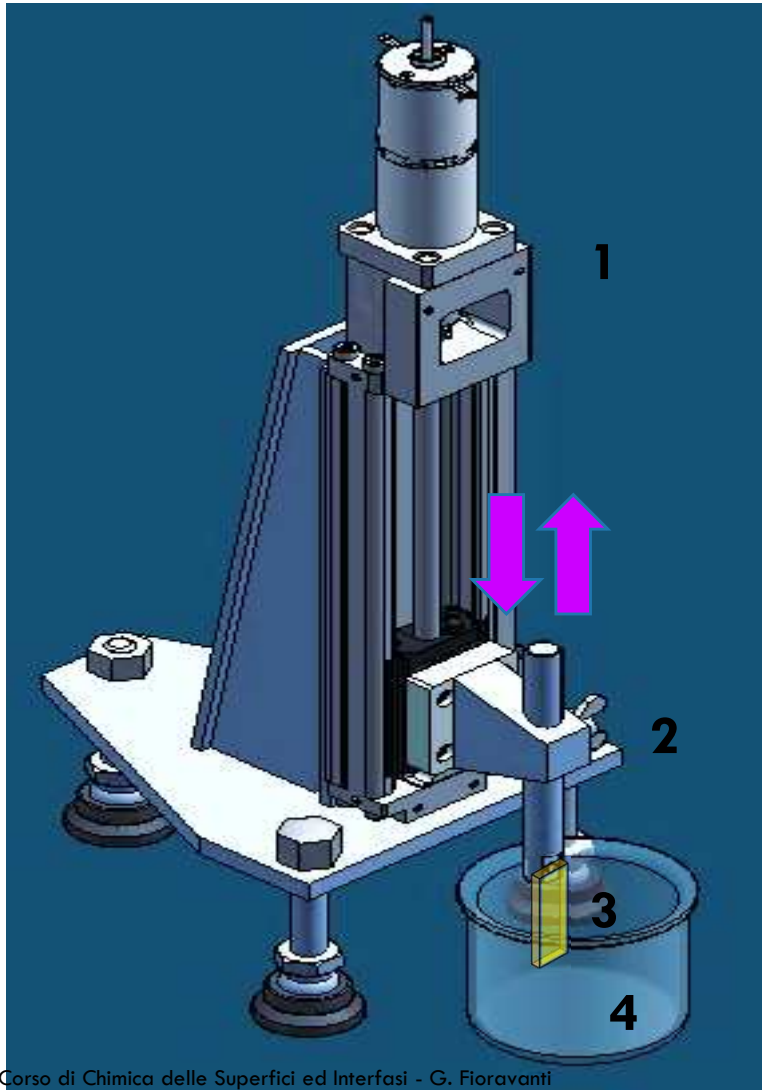
Water contact angles measured on a self-assembled monolayer (SAM) of 100% alkyl phosphonic acid (a), on a mixed SAM of 50% alkyl and 50% fluoroalkyl phosphonic acid (b), and on a SAM of 100% fluoroalkyl phosphonic acid (c).
Zschieschang et al, Adv. Mater. 2010, 22, 4489–4493.

CONTROLLED ADSORPTION

TWO-STEP IMMERSION METHOD

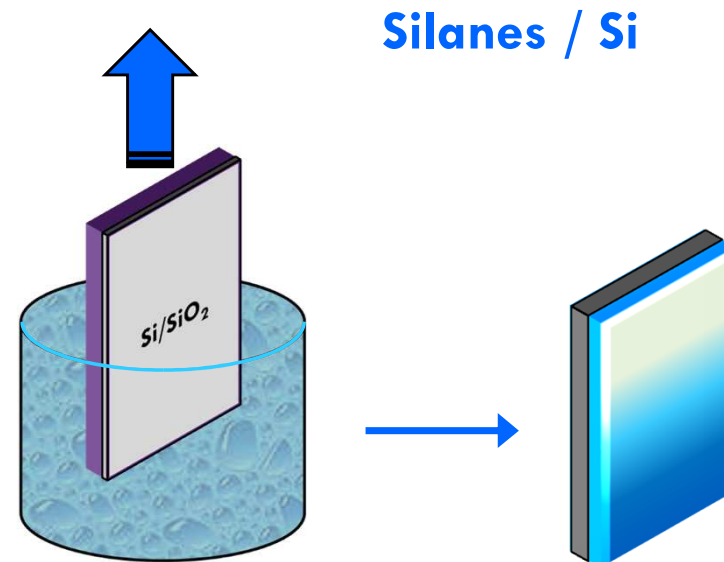
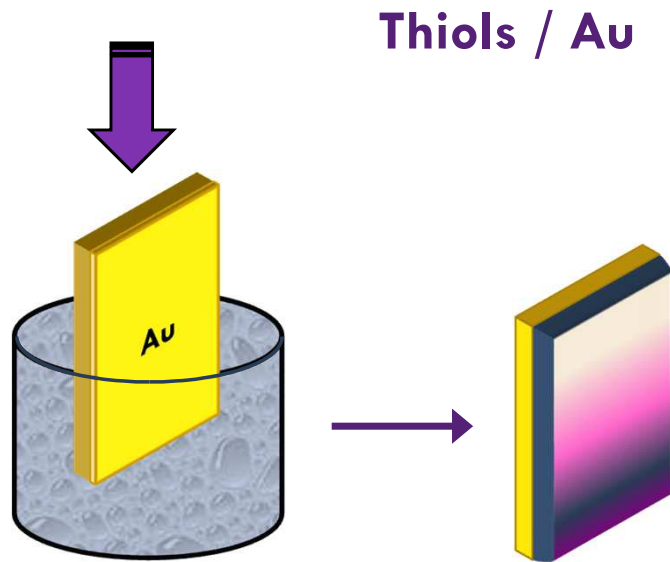
THE FIRST IMMERSION (OR EMERSION) IS PERFORMED BY USING A LINEAR MOTION DRIVE.

1. LINEAR MOTOR
2. SAMPLE HOLDER
3. SAMPLE
4. ADSORBATE SOLUTION 1



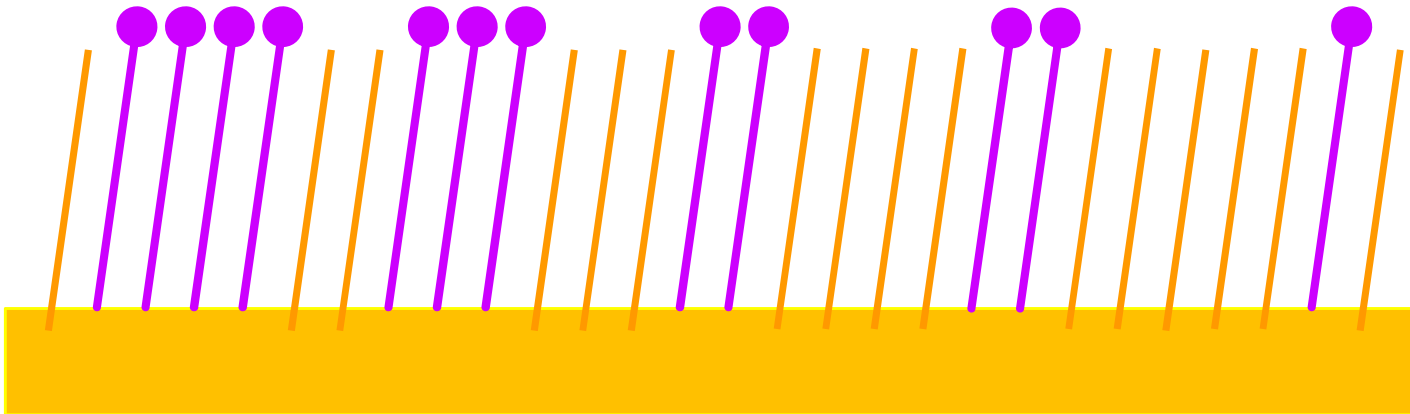
CONTROLLED ADSORPTION

DIPPING OR UNDIPPING STRATEGY (ADSORBATE 1)



SECOND STEP

- PARTIAL MONOLAYER
- FULL MONOLAYER (COMPLEMENTARY SAM)



THE SUBSTRATE WAS IMMERSED IN A SOLUTION CONTAINING ADSORBATE 2.

SAM COMPLEMENTARI

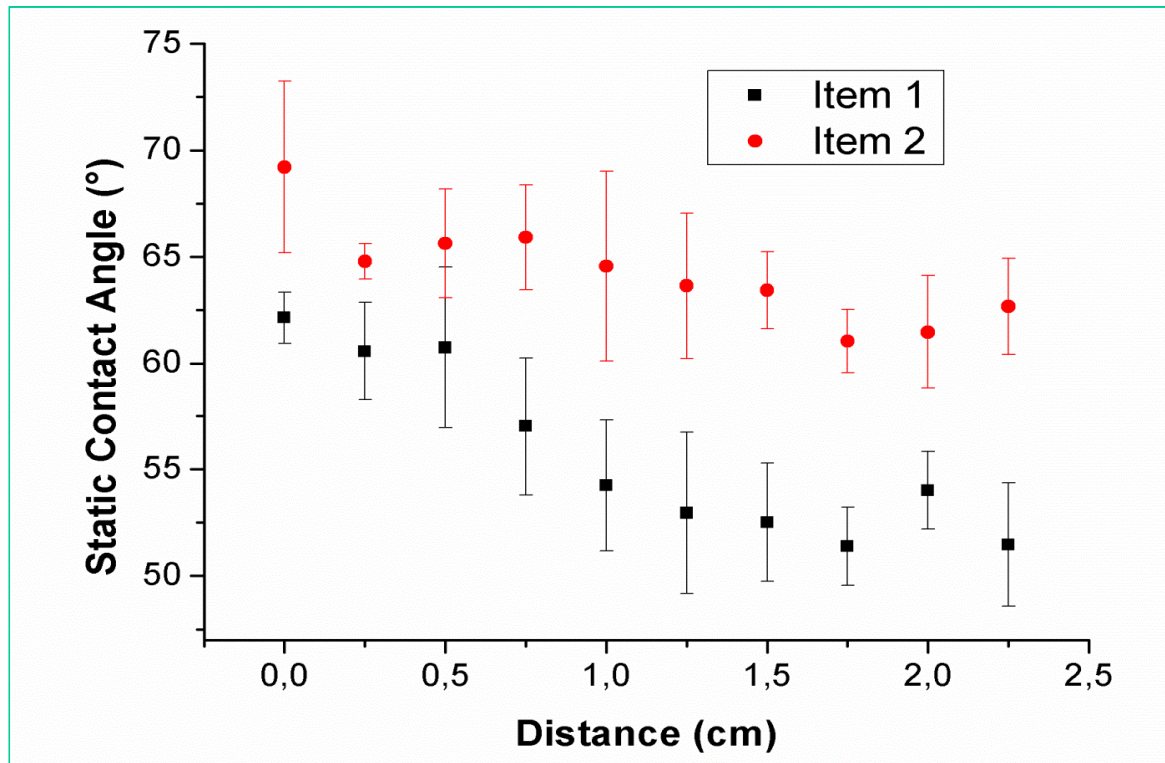
Substrate	Adsorbate 1	Type	Adsorbate 2	Type
Au	CH ₃ thiol	Dodecanthiol	OH thiol	11-Mercapto-1-Undecanthiol
	CH ₃ thiol	Dodecanthiol	COOH thiol	11-Mercapto Undecanoic acid
Si	CH ₃ silane	Octadecyltrichlorosilane or Butyltrichlorosilane	-	-
	Perfluoro silane	Trichloro(1H,1H,2H,2H PerfluoroOctyl)Silane	NH ₂ silane	Aminopropyl Triethoxysilane (APTES)

VARIABLES:

- THIOLS/SILANES CONCENTRATION
- SPEED OF WITHDRAWAL/DIPPING

CARATTERIZZAZIONE

CONTACT ANGLE MEASUREMENTS (WATER) Au SUBSTRATE/THIOLS



Item 1:

[CH₃] = 10⁻³ mM;

[OH] = 10⁻² mM;

speed = 20 μm/s

Item 2:

[CH₃] = 1 mM;

[OH] = 10⁻² mM;

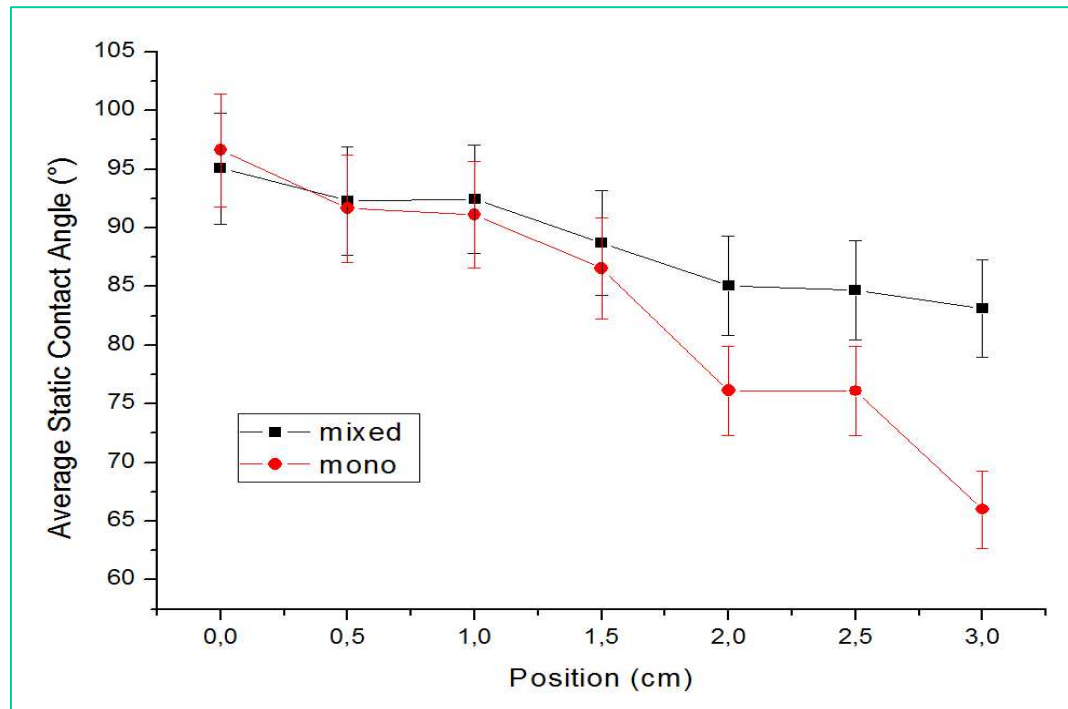
speed = 40 μm/s

RELATED OBSERVATIONS

- FULL COVERAGE OF MIXED THIOLS ON AU
- INFLUENCE OF ADSORBATE 1 CONCENTRATION (CH_3)
- LITTLE INFLUENCE OF ADSORBATE 2
- INFLUENCE OF LINEAR MOTOR SPEED (PARTIAL MONOLAYER)
- NOT MARKED WETTABILITY GRADIENT (NO DROPLETS MOVEMENT)
- NOT FLAT SURFACE (AU DEPOSITED ON GLASS)
- PRELIMINARY RESULTS (REPRODUCIBLE)

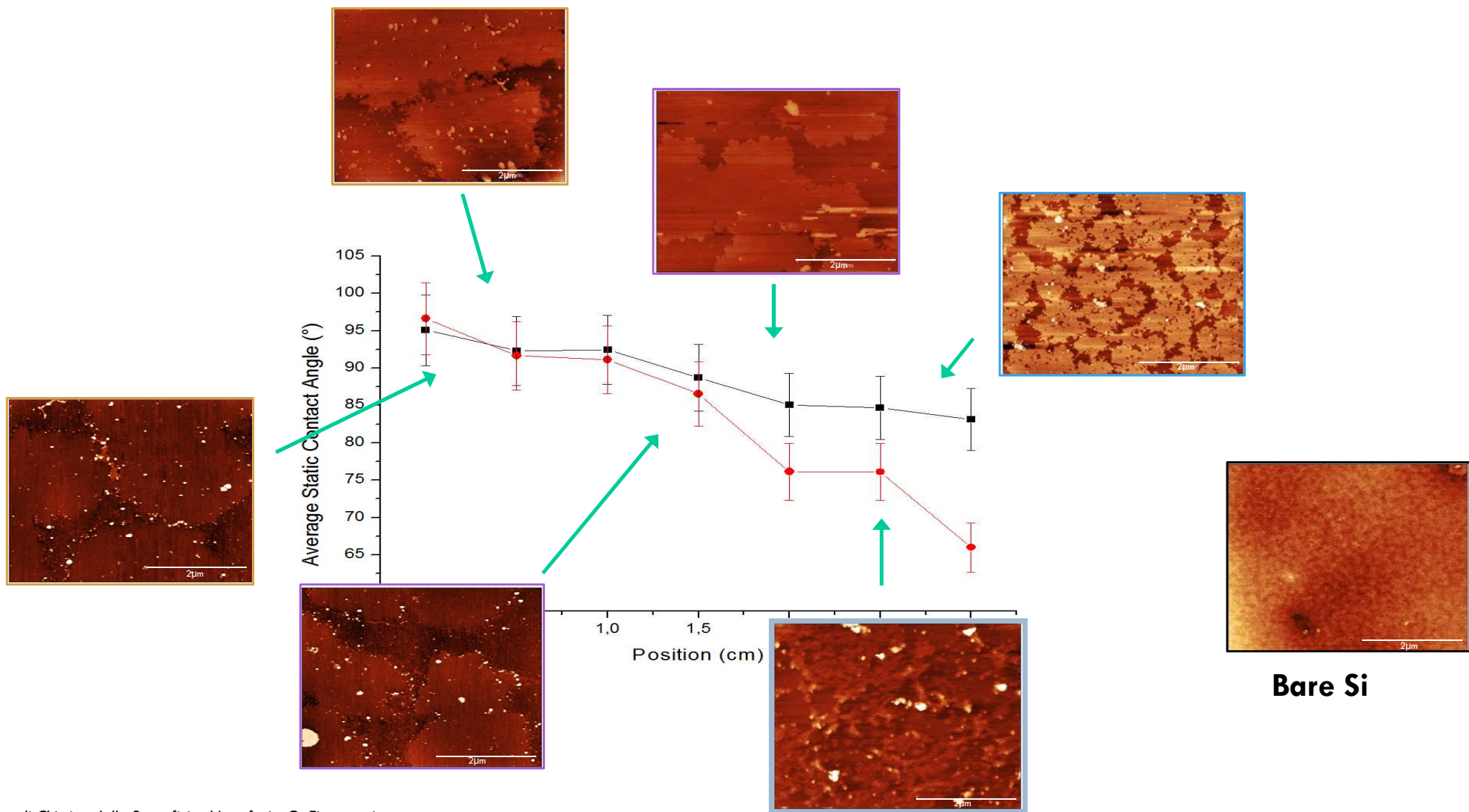
SILANES ON SI SURFACES

CONTACT ANGLE MEASUREMENTS (WATER) - Si SUBSTRATE/SILANES



MONO:
PERFLUORO OCTYLSILANE

MIXED:
PERFLUORO OCTYLSILANE +
AMINOPROPYL TRIETHOXYLANE

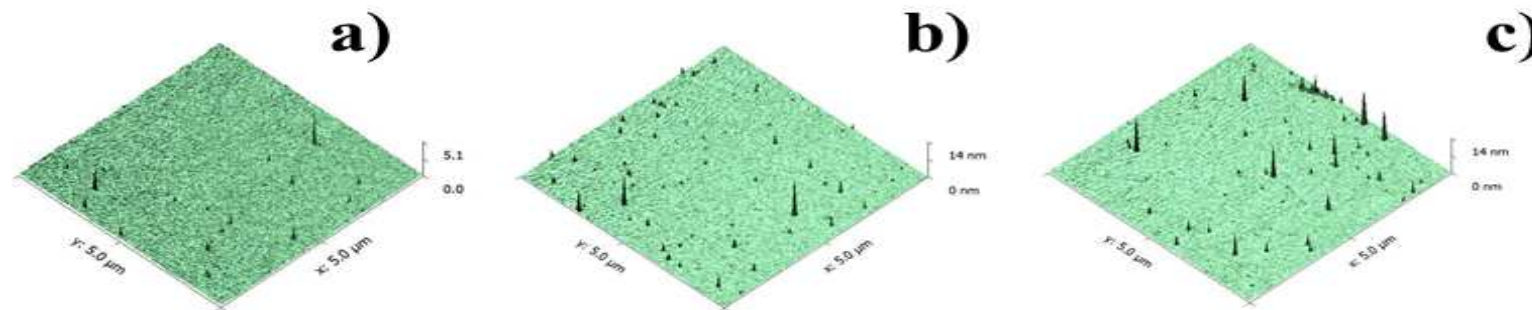


AFM CHARACTERIZATION

High coverage

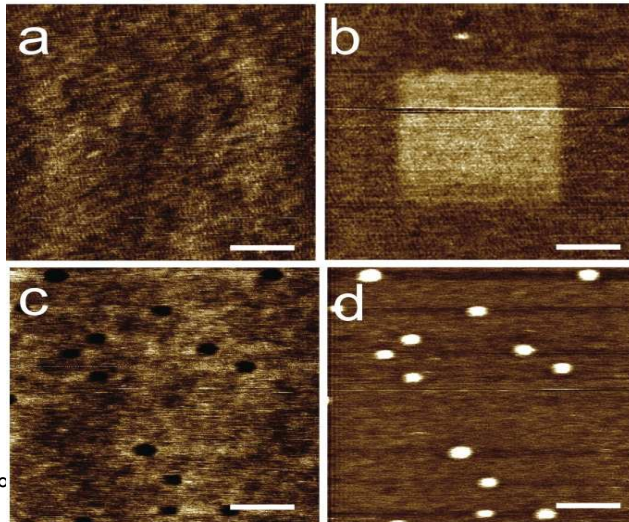


Low coverage



Topography

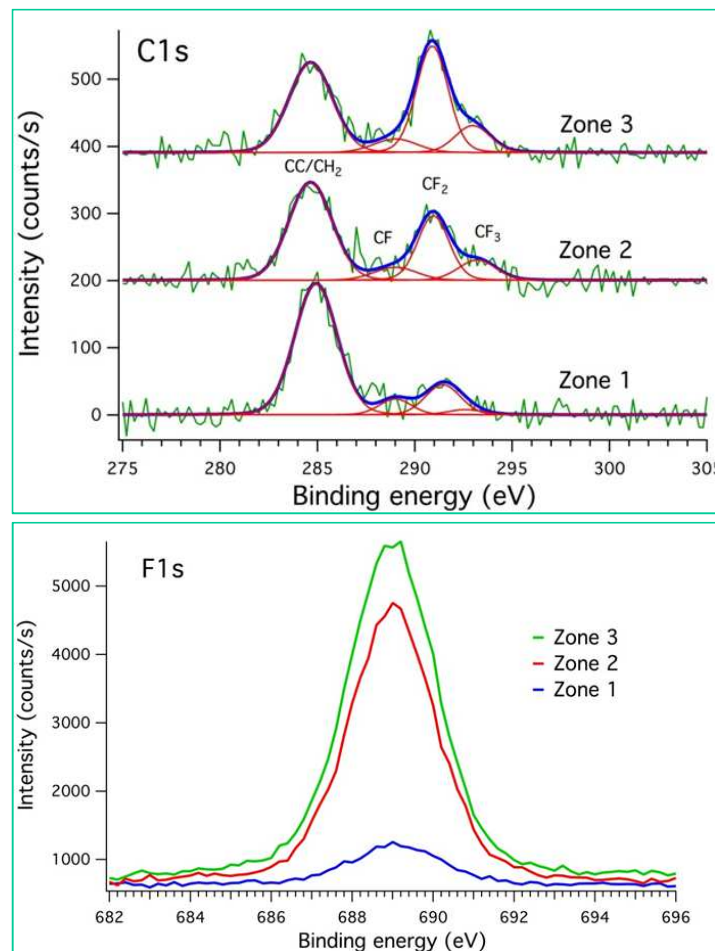
LFM



- Typical AFM topography of zone 1 (bar 1.5 μm z scale 1 nm)
- Corresponding LFM image recorded with 1 nN load force after nanorubbing using 4 nN loading force in the central zone.
- Typical AFM topography of zone 3 (bar 1.5 μm z scale 1.5 nm)
- Corresponding LFM image of c.

XPS CHARACTERIZATION

XPS characterization: C1s and F1s evolution in the three regions of the wettability gradient.



Zone 3

High coverage

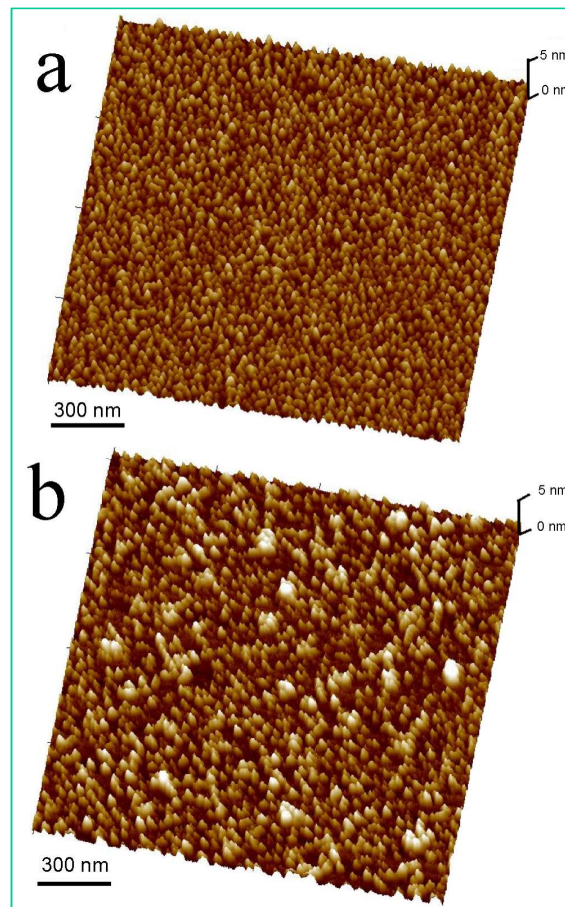
Zone 2

Zone 1

Low coverage

AFM CHARACTERIZATION

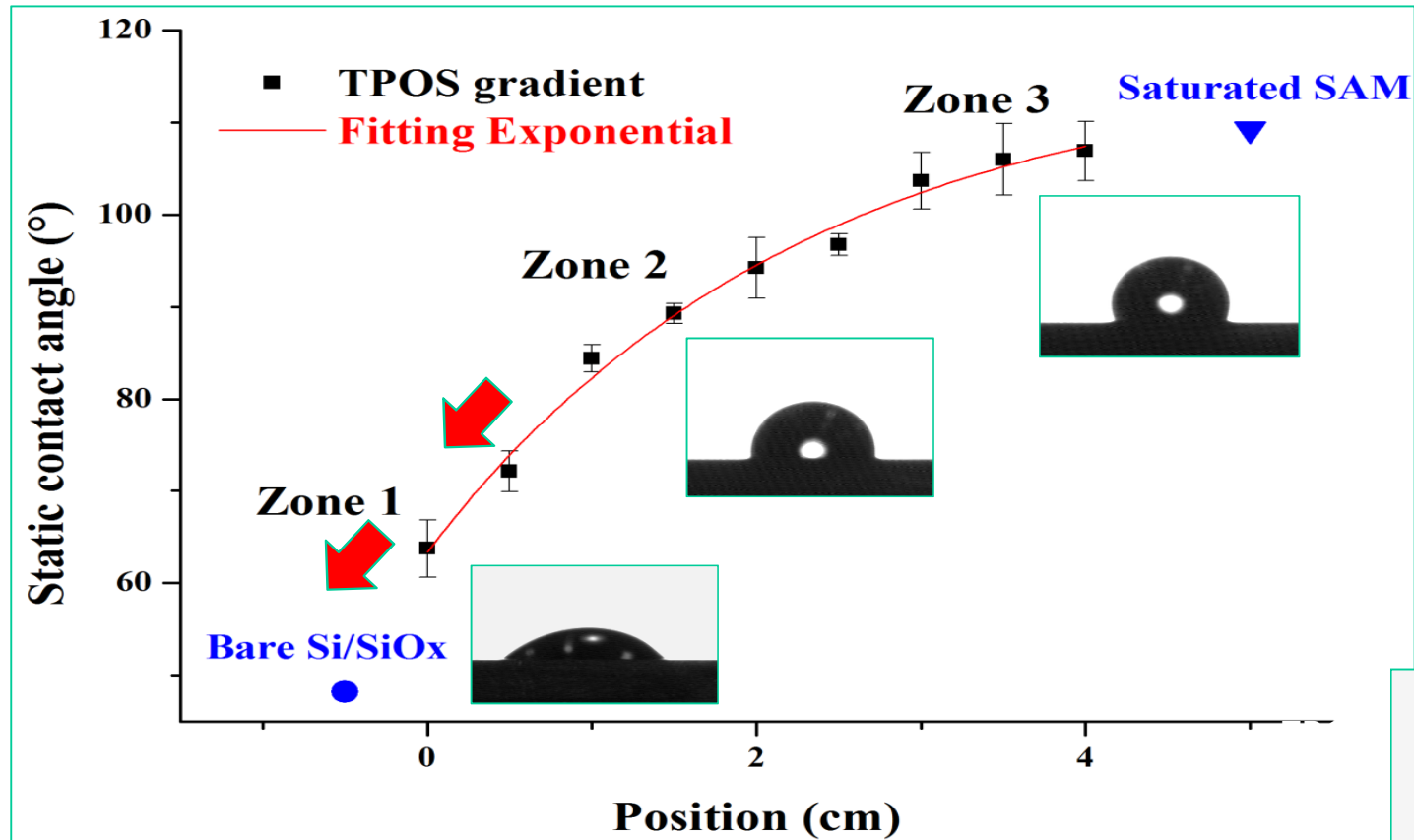
Typical AFM images of silicon surface functionalized by TPOS corresponding to a) zone 1 and b) zone 3 of the samples.



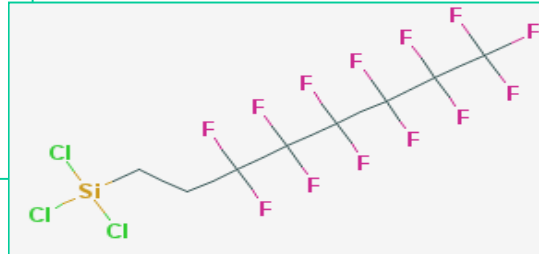
High coverage

Low coverage

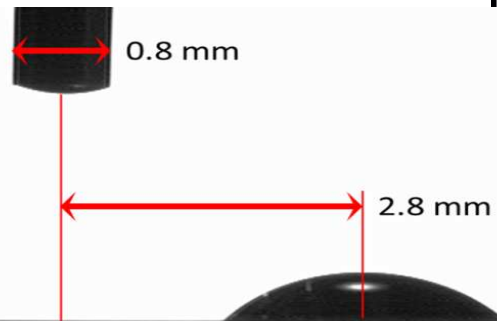
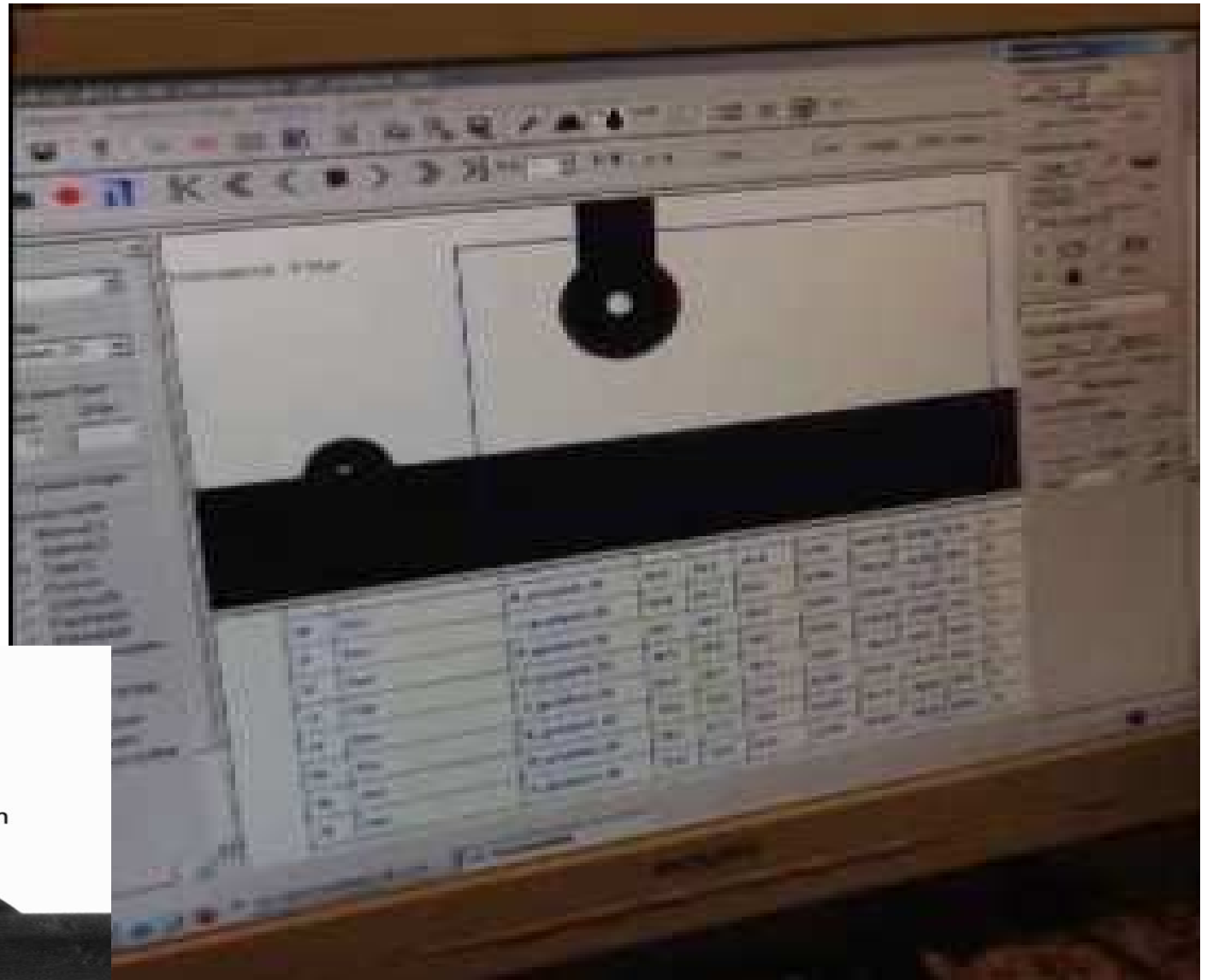
SILANES ON SI SURFACES



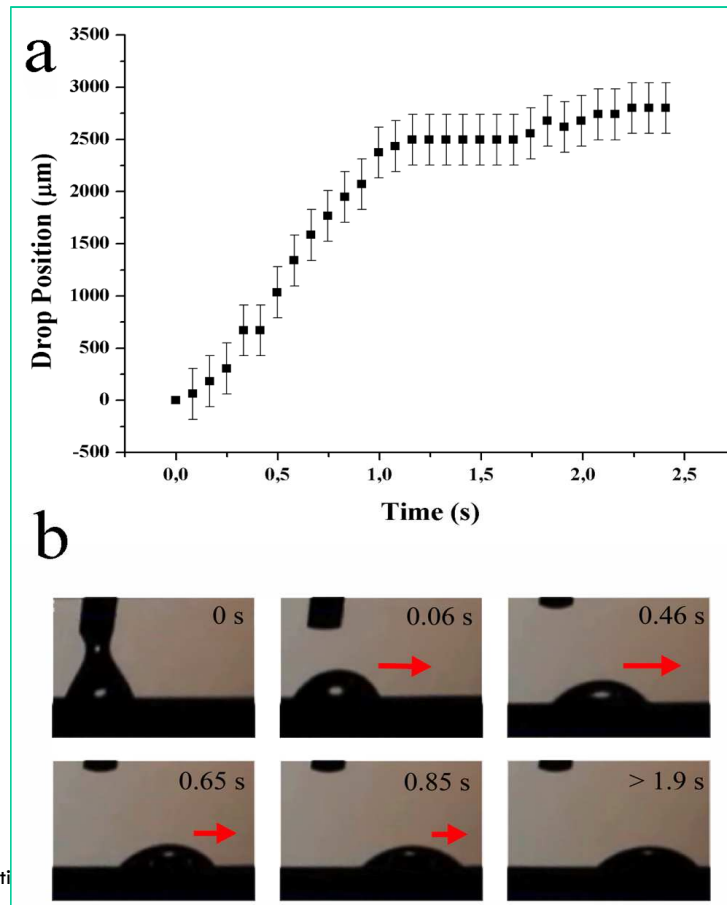
Static Water Contact Angle measurements along the gradient and exponential fit. Measurements at 25 °C in air.



DROPLET MOVEMENT



DROPLET MOVEMENT



- a) Plot of the droplet position of the drop during the movement along the gradient.
- b) Images of the droplet in motion. The red arrows are proportional to the velocity of the movement.

RELATED OBSERVATIONS

- MARKED SLOPE IN WETTABILITY GRADIENT (105-60°)
- DROPLETS MOVEMENT ($\Delta\theta/\Delta x > 10^\circ$)!!!
- SILANES COVERAGE CONFIRMED BY XPS ANALYSIS
- FLAT SURFACE USEFUL FOR LATERAL FORCE AFM (?)
- PROBLEMS IN REPRODUCIBILITY (?)
- PROBLEMS IN DYNAMIC CONTACT ANGLE MEASUREMENTS

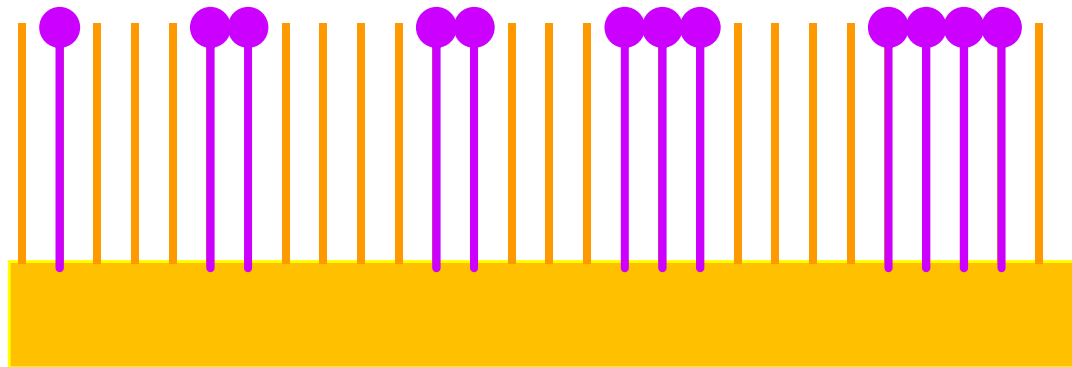
WECD - WITHDRAWAL ELECTROCHEMICAL DESORPTION

- NEW TECHNIQUE
- DESORPTION WHILE WITHDRAWING THE SUBSTRATE
- APPLICABLE TO ANY METALLIC SURFACES COVERED BY THE PROPER ADSORBATE
- EASY AND REPRODUCIBLE

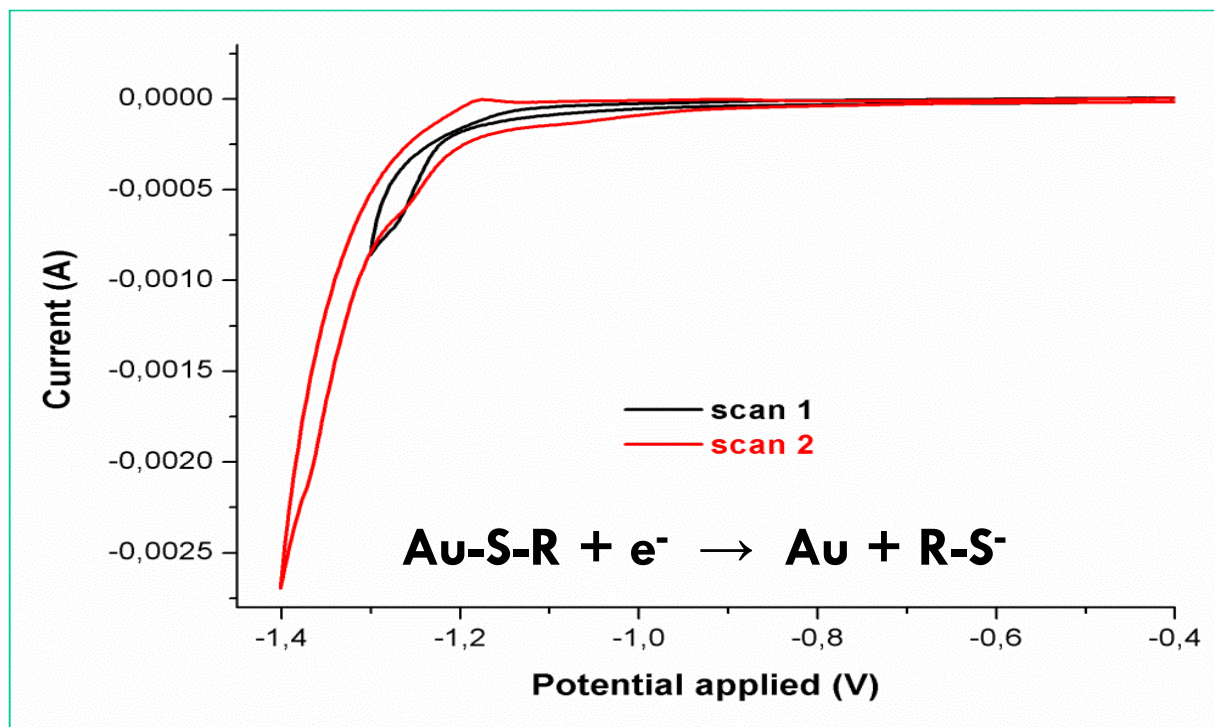


WECD - WITHDRAWAL ELECTROCHEMICAL DESORPTION

- FIRST STEP: FULL COVERAGE OF THIOLS (CH_3) ON AU
- SECOND STEP: CONTROLLED ELECTROCHEMICAL DESORPTION (PARTIAL COVERAGE)
- THIRD STEP: COMPLEMENTARY ADSORPTION (OH)



ELECTROCHEMICAL DESORPTION



0.5 M KOH solution
in Millipore water

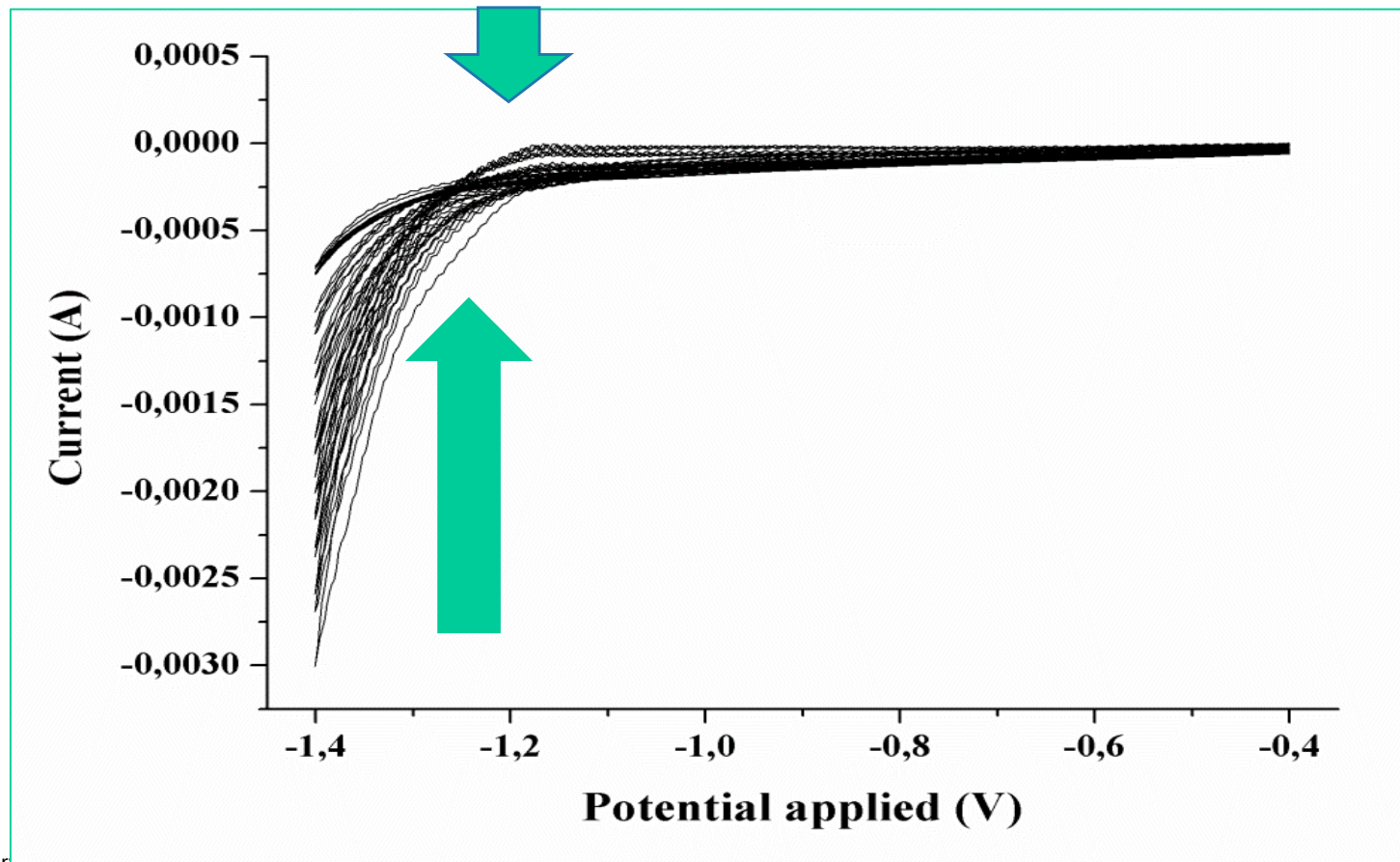
Reference: Ag/AgCl
Counter: Pt sheet

Working: SAM
covered surface

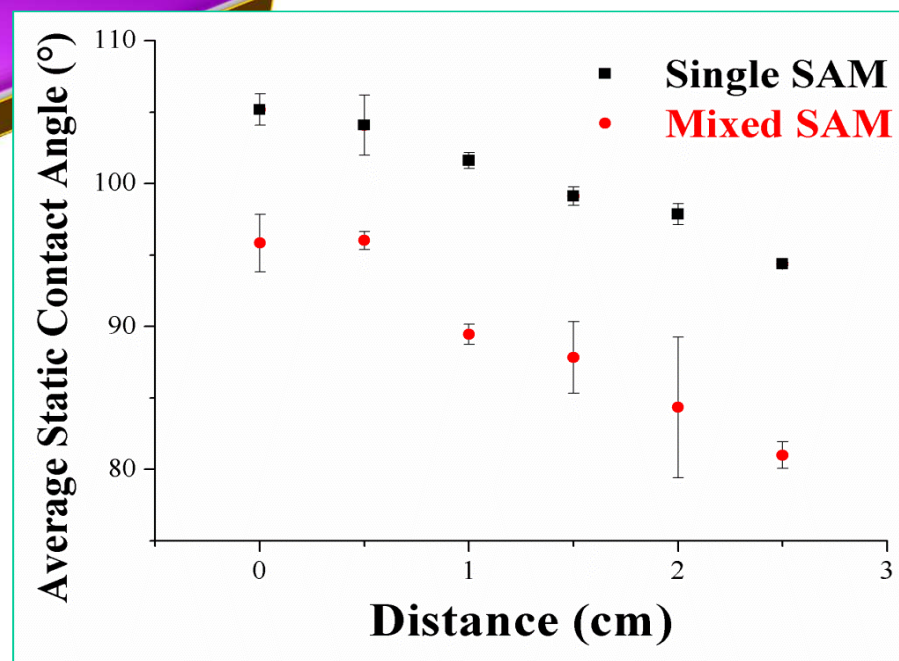
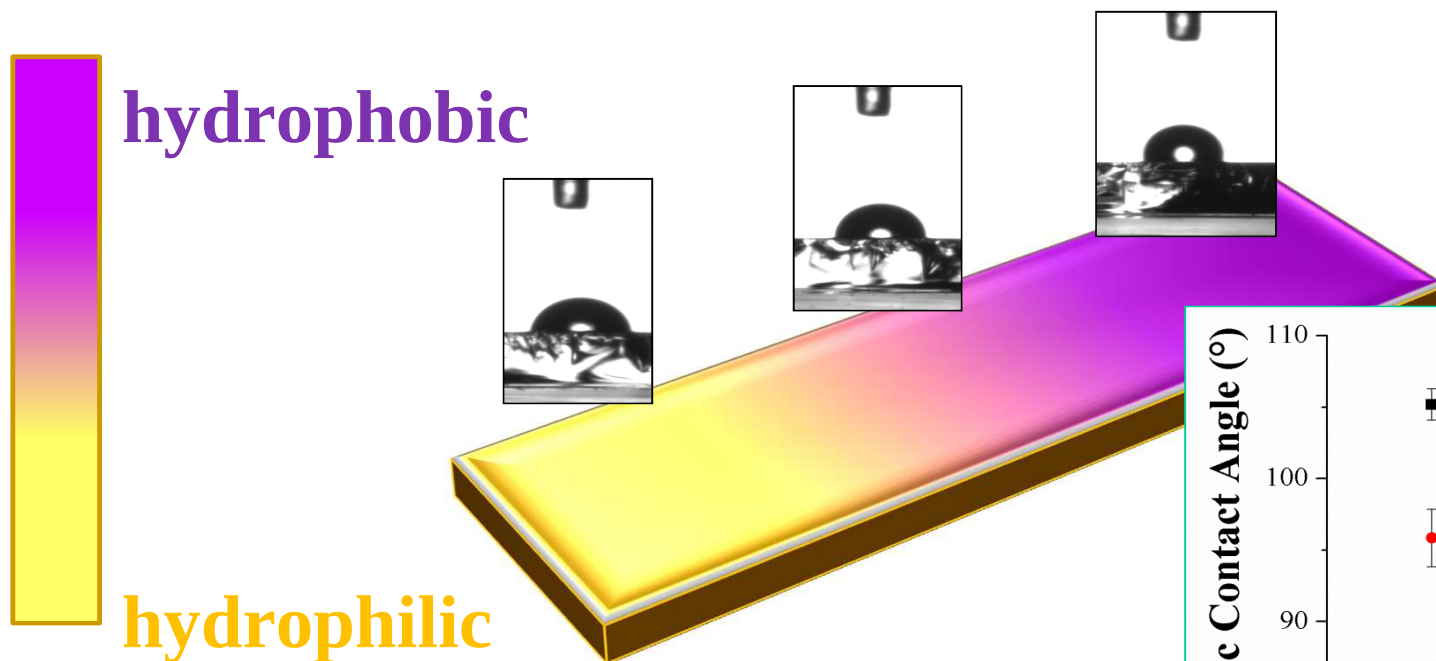
Speed: 100 mV/s

Cycling from a voltage of -0.40 V to -1.40 V, and then returning to -0.40 V.

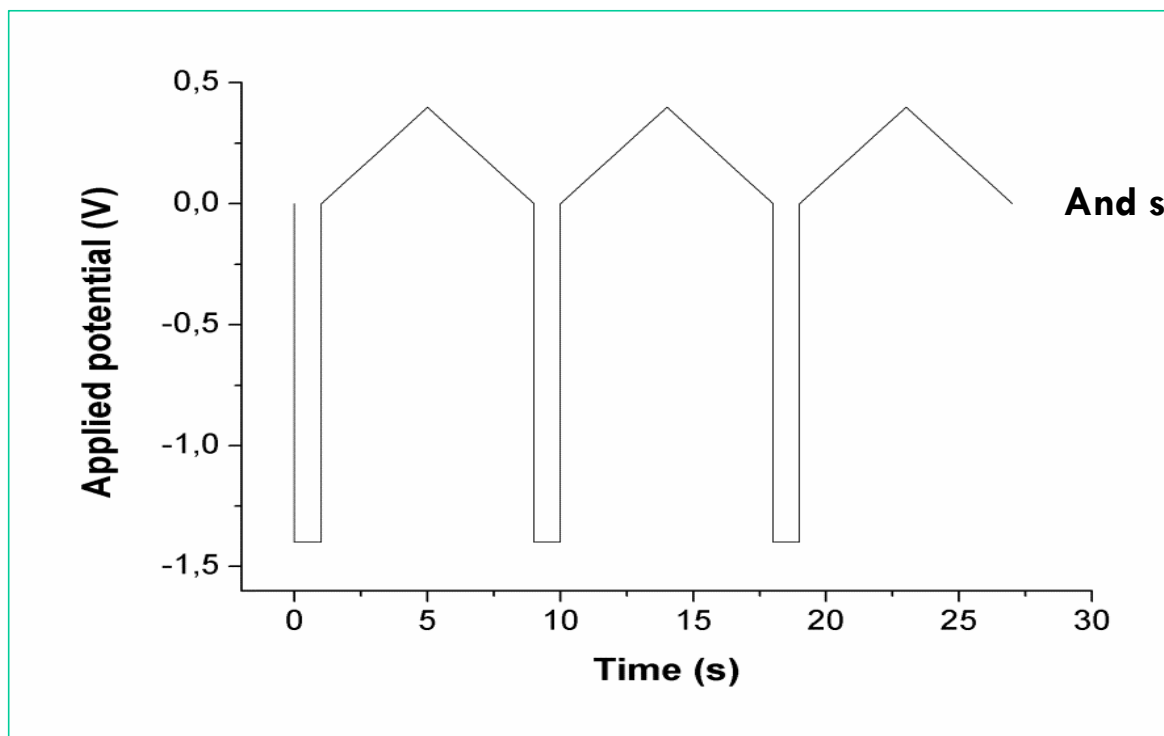
ELECTROCHEMICAL DESORPTION



CONTACT ANGLE MEASUREMENTS



TIME DESORPTION



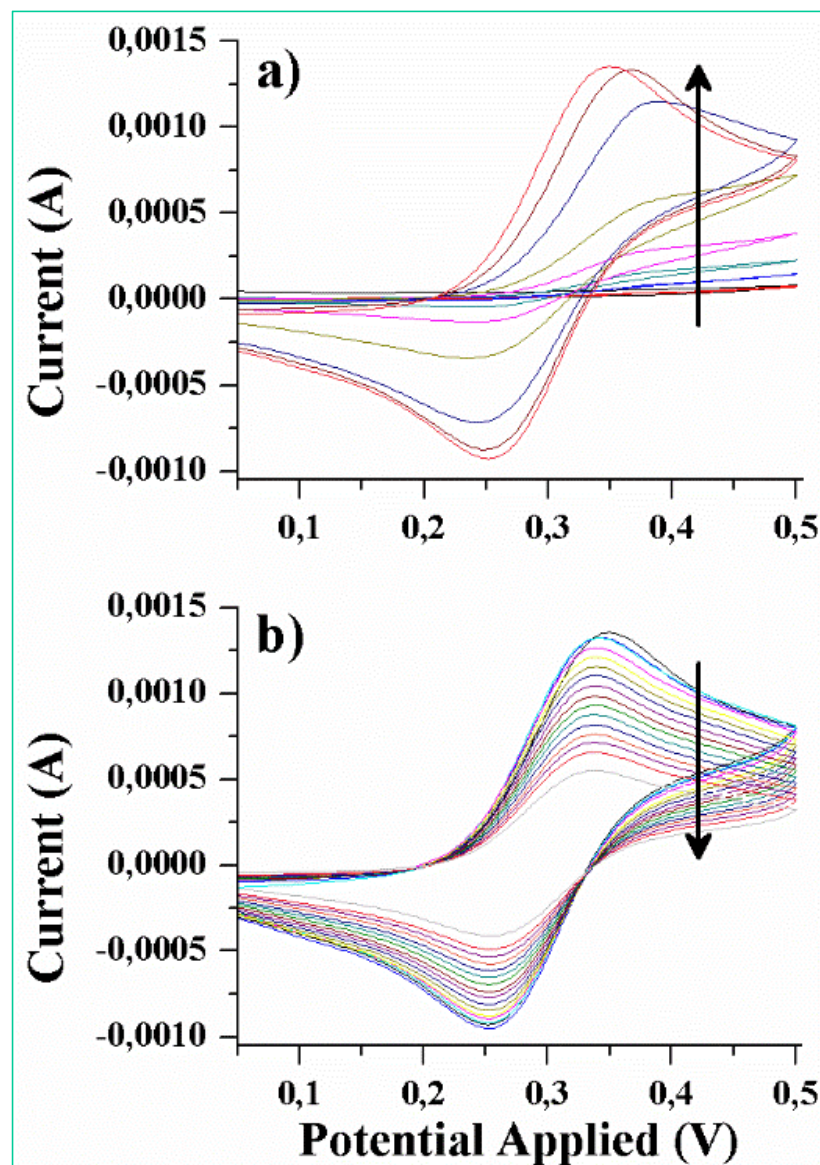
Speed = 100 mV/s;
Reference electrode: Ag/AgCl;
Counter electrode: Pt wire;
Working electrode: SAM/Au.

TIME DESORPTION - CV

Solution:

0.5 M potassium hydroxide (KOH) and
5.0 mM of ferricyanide $\text{K}_3\text{Fe}(\text{CN})_6$

a) Repeated cyclic voltammtries from 1 to 9 cycles. b) Repeated cyclic voltammtries from cycle 10. Reference electrode: Ag/AgCl; Counter electrode: Pt wire; Working electrode: SAM/Au; 0.5 M potassium hydroxide (KOH) and 5.0 mM of potassium ferricyanide $\text{K}_3\text{Fe}(\text{CN})_6$ solution; Speed = 100 mV/s.

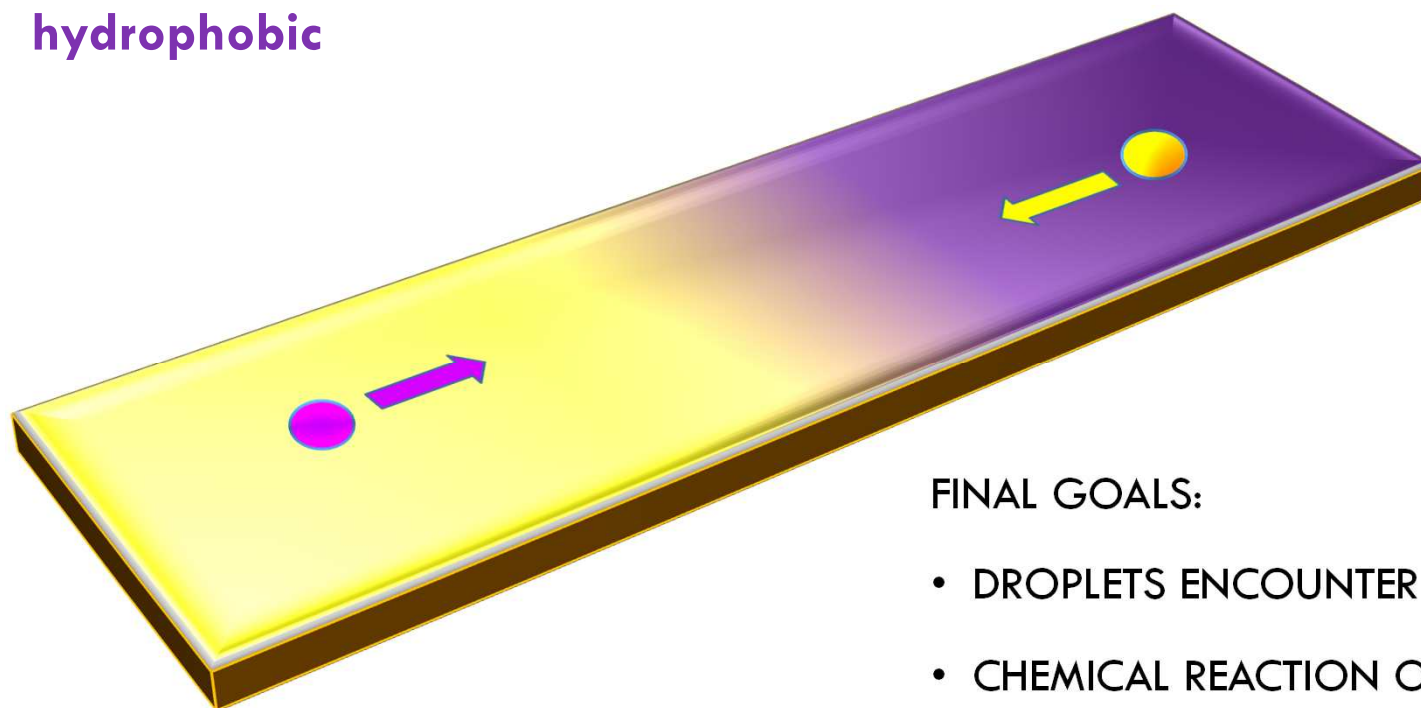


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- NOT FLAT SURFACE (AU DEPOSITED ON GLASS)
- PRELIMINARY RESULTS (REPRODUCIBLES)

DROPLETS MOVEMENT ON SURFACE

hydrophobic



● Solvent 1

● Solvent 2

FINAL GOALS:

- DROPLETS ENCOUNTER
- CHEMICAL REACTION ON SURFACE

hydrophilic

THE END!!!